Dopant-Controlled Morphology Evolution of WO₃ Polyhedra Synthesized by RF Thermal Plasma and Their Sensing Properties

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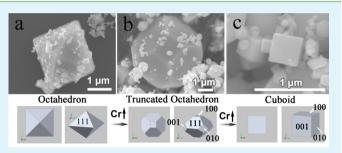
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(5) Supporting Information

ABSTRACT: In this paper, a simple way is developed for the synthesis of Cr-doped WO₃ polyhedra controlled by tailoring intrinsic thermodynamic properties in RF thermal plasma. Scanning electron microscopy, transmission electron microscopy, X-ray diffraction, and X-ray photoelectron spectroscopy are used to characterize the detail structures and surface/near-surface chemical compositions of the as-prepared products. Kinetic factors showed little effects on the equilibrium morphology of Cr-doped WO₃ polyhedra, while equilibrium morphologies of WO₃ polyhedra can be controlled by the



thermodynamic factor (Cr doping). Set crystal growth habits of pure WO₃ as an initial condition, coeffects of distortions introduced by Cr into the WO₃ matrix, and a chromate layer on the crystal surface could reduce the growth rates along [001], [010], and [100] directions. The morphology evolution was turning out as the following order with increasing Cr dopants: octahedron-truncated octahedron-cuboid. 2.5 at. % Cr-doped WO₃ polyhedra exhibit the highest sensing response due to coeffects of exposed crystal facets, activation energy, catalytic effects of Cr, and particle size on the surface reaction and electron transport units. By simply decorating Au on Cr-doped WO₃ polyhedra, the sensing responses, detection limit, and response-recovery properties were significantly improved.

KEYWORDS: WO₃, dopant, crystal growth habit, RF thermal plasma, MOX sensors

1. INTRODUCTION

Crystals with different types of exposed facets usually exhibit various physical and chemical properties; such anisotropy is one of the basic properties of crystals.¹ The final shape of a crystal and the exposed facets are a result of the interplay between thermodynamics (e.g., selective adsorption of capping or stabilizing reagents^{2,3}) and kinetics (e.g., the crystal growth rate during the nucleation and growth of crystals^{4,5}). However, the understanding of the synthesis of crystals with specific facets and the relationship between activity and surface structure is still limited,¹ especially for those synthesized by chemical vapor deposition (CVD). In addition, the dopantcontrolled octahedron-to-cuboid morphology evolution of WO₃ crystals has not been reported so far.

Since the temperature of the flame is ultrahigh (up to 10^4 K), nuclei are formed without substrates/catalysts, and the supply of atoms to the nuclei are almost equal in all directions, the crystal thermal equilibrium morphologies in RF thermal plasma are in fact determined by crystal growth habits (intrinsic thermodynamic properties) and in some cases affected by kinetic factors when the growth rate of the crystal is sensitive.

We have successfully prepared ZnO nanowires, ZnS nanobelts, and WO₃ octahedra with specific exposed facets via RF thermal plasma method^{6–8} and found that the morphologies of ZnO and ZnS with sensitive [001] growth direction could be changed by kinetic factors, while the morphology of WO₃ could only be determined by its crystal growth habit.

WO₃ is a transition metal oxide with wide range of applications such as photocatalysis,⁹⁻¹² gas sensors,^{7,13} anode materials of Li-ion batteries,¹⁴ supercapacitors,¹⁵ field emitters,¹⁶ electrochromic (EC) devices,^{17,18} and so on. To obtain nanostructures with specific exposed facets and hierarchical structures, tungsten oxides were synthesized using varying techniques to form zero-dimensional (0D),^{3,7,19,20} 1D,^{21,22} 2D,^{13,23,24} and 0²⁵/1²⁶/2D-based^{27,28} hierarchical structures. Among these, morphology-controlled syntheses of 0D WO₃ crystals with exposed specific facets are of great significance to

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the understanding of both their synthesis and the relationship between activity and surface structure.

In RF thermal plasma, WO₃ products without dopants showed octahedral shapes with {111} exposed facets due to fast growth rate along [001], [010], and [100] directions.⁷ Doping might be an ideal candidate to tailor exposed facets of WO₃ due to its potential for affecting the crystal growth habit (i.e., growth rates along different crystal directions). Cr-WO₃ with polyhedral shape and tunable exposed specific facets cannot be achieved either by liquid phase methods or other vapor phase methods so far. Herein, a study of the doping effect of Cr elements on the shape of WO₃ polyhedra synthesized by RF thermal plasma was demonstrated. The morphologies were controlled by tailoring the corresponding crystal growth habits via Cr doping. With increasing Cr dopants, the morphologies changed according to the following order: octahedrontruncated octahedron-cuboid. The gas sensing properties were also studied here.

2. MATERIALS AND METHODS

2.1. Preparation of the Precursor: Cr-APT. The precursors of Cr-doped WO₃ polyhedra were obtained according to the following steps. First, 300 g of ammonium paratungstate tetrahydrate powder (APT, Ganzhou Tejing Tungsten and Molybdenum Co.,Ltd., China) was mixed with 37 mL of aqueous solution of ammonium chromate (~0.70 M for 2.5 at. % sample, Beijing Chemical Co., Ltd., China). Then the mixture was moved to a vacuum oven (40 °C) for 12 h, and the dried mixture was ground in a mortar and passed through a 100-mesh sieve repeatedly. The final mixture was marked as Cr-APT. It should be noted that the surface area of APT limits the amount of ammonium chromate coated on its surface (up to 10 at. %). Higher than 10 at. % will result in the mixture of Cr-APT and ammonium chromate powders.

2.2. Synthesis of Cr-Doped WO₃ Polyhedra, Cr_2O_3 , and WO₃ Octahedra. The syntheses of Cr-doped WO₃ polyhedra, Cr_2O_3 , and WO₃ octahedra were carried out in an RF thermal plasma system under atmospheric pressure. The schematic illustration of the system is available in in our previous works,^{7,29} and the modified product collecting system is shown in Figure 1a.

The reactor consists of a vertical quartz tube of 5 cm diameter and 15 cm length. Cr-APT/ammonium paratungstate tetrahydrate/APT was subjected to thermal decomposition in $Ar-O_2$ plasma as received, and the produced Cr-doped WO₃ polyhedra/Cr₂O₃/WO₃ octahedra were collected at the bottom of the chamber (Figure 1a). The detailed parameters for the plasma processing are given in Table 1.

2.3. Synthesis of Au-Decorated **2.5** at. % Cr-Doped WO₃ Polyhedra. The synthesis of Au-decorated 2.5 at. % Cr-doped WO₃ polyhedra was modified from the report of Zhang et al.³⁰ First, 0.20 g of 2.5 at. % Cr-doped WO₃ polyhedra was dispersed in 60 mL of HAuCl₄ (1 mM) aqueous solution under stirring, and 20 mL of NH₃. H₂O (3 M) was added. After stirring for about 3 h, the precipitate was collected by centrifugation at 4000 rpm and washed with deionized (DI) water and absolute ethanol for several times and then dried at 80 °C for 4 h. The resulting brown precursor was annealed at 350 °C for 1 h, and the Au-decorated 2.5 at. % Cr-doped WO₃ polyhedra with a purple-brown color were finally obtained.

2.4. Materials Characterization. The phase and crystal structures of the products were determined by X-ray diffraction (XRD) patterns, which were recorded with a Philips X'Pert PRO MPD X-ray diffractometer using Cu K α radiation ($\lambda = 1.54178$ Å). The morphology and structure of the product were then observed by scanning electron microscope (SEM, JEOL JSM-6700F) and transmission electron microscope (TEM, JEOL JEM-2100). N₂ adsorption was measured by a BET instrument using a surface area analyzer (NOVA3200e, Quantachrome, U.S.A.). The particle size distribution of the synthesized powder was determined using a Beckman Coulter LS 13 320 laser-diffraction particle size analyzer. The surface chemical analysis was investigated by X-ray photoelectron spectroscopy (XPS)

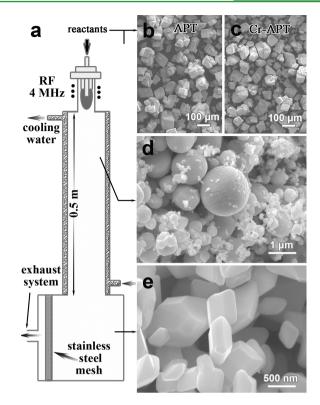


Figure 1. (a) Schematic diagram of the RF-induced plasma setup and SEM images of (b) APT, (c) Cr-APT, (d) particles collected from the upper part of the chamber, and (e) particles collected from the bottom collector.

Table 1	. Parameters	of $Ar - O_2$	Plasma	Processing

values
15 kW
$0.6 \text{ m}^3 \text{ h}^{-1}$
$2.0 m^3 h^{-1}$
$0.3 - 0.6 \text{ m}^3 \text{ h}^{-1}$
50–100 mm H ₂ O
$5-20 \text{ g min}^{-1}$

on a Thermo Scientific ESCALAB 250 Xi XPS system, where the analysis chamber was 1.5×10^{-9} mbar and the size of X-ray spot was 500 μ m.

2.5. Fabrication of Gas Sensor Prototype and Sensor Characterization. The fabrication of gas sensor prototypes and the sensor characterization were reported in our previous works.^{29,31} Briefly, the solution containing sensing material and ethanol was drop-coated onto the Al₂O₃ substrate with two Ag electrodes. Then the sensor was preheated at 550 °C for 2 h and stabilized at 400 °C for 20 h to ensure good ohmic contact. Target gas was introduced into the quartz tube by mixing the certified gas ""mixtures"" and dry air in the proper ratio controlled by the mass flow controllers.³² The constant flow was 600 mL min⁻¹, the bias on the sensor was 5 V, and the current was recorded using Keithley 2601 Sourcemeter. The response was defined as the ratio of sensor resistance in air and in detected gas ($R_{\rm air}/R_{\rm gas} - 1$). The response time was defined as the time required for the resistance of the sensor to change to 90% of the saturation value after exposure to the test gas.

3. RESULTS AND DISCUSSION

3.1. Materials Preparation and Characterization. Figure 1 shows the schematic illustration of the RF-induced plasma setup and the corresponding SEM images of the reactants and the products collected at different parts of the system (2.5 at. % Cr-doped WO₃ as an example). It can be seen that both APT and Cr-APT are separate particles with a diameter of hundreds of micrometers and good flowability, which is beneficial to the continuous feed.

3.1.1. Effect of Kinetic Factors. Affected by the quenching rate, an important kinetic factor for vapor phase method, products collected showed two types of morphologies, which were spheres and crystals with specific exposed facets (Figure 1d and e). It is well-known that the lowest energy surface for a liquid droplet is a sphere. The quenching rate was ultrahigh for the powders formed in the upper part of the chamber (surrounded by cooling water); therefore, the surface atoms of the condensed spherical droplets lose their energy very fast and do not move around,^{20,33} which resulted in the formation of spherical particles. In contrast, the surface atoms of the particles condensed at a low quenching rate lost their energy slowly, and equilibrium forms were formed. The equilibrium forms were found to be polyhedra with regular shapes (truncated octahedra for 2.5 at. % Cr-doped WO₃). Considering differences in dwell time in high-temperature region for further crystal growth, it is easy to understand that rapid quenching in the upper part of the chamber resulted in smaller mean size (0.52 μ m) and less stable phase (61 wt %, γ -WO3, semiquantitative concentration calculated by X'pert Highscore software) than those formed by slow quenching (0.69 µm and 73 wt %, Table 2).

Table 2. Effects of Some Kinetic Factors on the Morphology and Crystal Phase of 2.5 at. % Cr-Doped WO₃

quenching rate	powder feeding rate (g min ⁻¹)	sheath gas, oxygen (m ³ h ⁻¹)	carrier gas, oxygen (m ³ h ⁻¹)	mean size (µm)	stable phase (wt %)	
slow	5	2.0	0.3	0.69	73	
rapid	5	2.0	0.3	0.52	61	
slow	20	2.0	0.3	0.60	80	
slow	5	2.0	0.6	0.56	71	
^{<i>a</i>} Stable phase refers to semiquantitative concentration wt % of γ -WO ₃						

calculated by X'pert Highscore software

Other kinetic factors showed little effects on the equilibrium morphology of 2.5 at. % Cr-doped WO₃. For example, by increasing the amount of Cr-APT subjected into the plasma jet from 5 to 20 g min⁻¹, the obtained products showed more stable phase (80 wt %) and smaller mean size (0.60 μ m) without changing equilibrium morphology. As we know, the nucleation rate increases with the increasing supersaturation, and thus large numbers of nuclei were formed and grew homogeneously; this led to narrow particle distribution and small mean size. More stable phase might be ascribed to vigorous decomposition and small size (effective annealing).

We decreased the dwell time of the particles in the hightemperature region by increasing the flow rate of carrier gas. It resulted in smaller mean size (0.56 μ m) and less stable phase (71 wt %) due to less time for further crystal growth and annealing, respectively. The equilibrium morphology of 2.5 at. % Cr-doped WO₃ remained unchanged.

3.1.2. Effect of Thermodynamic Factors (Cr Dopants). Since kinetic factors cannot changed the equilibrium morphologies of Cr-doped WO_3 products, the effects of thermodynamic factors were studied. However, common methods such as selective adsorption of capping or stabilizing agents cannot be realized in RF thermal plasma. Therefore,

doping would be an ideal method to tailor the equilibrium morphologies of Cr-doped WO_3 products due to its potential for affecting the crystal growth habit (i.e., growth rates along different crystal directions).

3.1.2.1. Effect of Thermodynamic Factors on Morphology Evolution (Cr Dopants). The crystallographic structures of the products were investigated by XRD and showed the typical patterns of the standard monoclinic γ -WO₃ (Figure 2a, JCPDS No. 00-083-0950, also named as monoclinic I). A metastable weak phase called ε -WO₃ (JCPDS No. 01-087-2404) was also observed (Figure 2b and d). The intensities of diffraction peaks declined as Cr concentration increased, indicating that Cr dopants within WO₃ caused degeneration of the crystallinity (Figure 2a–c). It can be seen that Cr dopants also reduce the intensities of (002) and (200) peaks and finally result in the fact that the intensities of (002), (020), and (200) are close to each other, which reflects changes in morphology. Figure 2 also shows that Cr-doped WO₃ products were prepared without the formation of a new phase.

It can be seen in Figure 2a–c that Cr dopant slightly shifts the positions of XRD peaks to higher diffraction angles, which is consistent with Cr-doped WO₃ particles reported by other researchers.³⁴ The only exception is 10 at. % sample, which might due to its poor crystallinity (Figure 2b, light blue). Similar phenomenon was observed when 2.5 at. % sample with poor crystallinity (collected from the upper part of the chamber) was measured (Figure 2d, green).

Figure 3 shows the Raman spectra of as-synthesized and heat-treated products, respectively. In these spectra, peaks at 272, 324, 715, and 805 cm⁻¹ correspond to γ phase³⁵ and peaks at 203, 272, 303, 370, 425, 642, 688, and 805 cm⁻¹ belong to the ε phase.³⁶ The bands at 942 and 992 cm⁻¹ can be assigned to the stretching mode of W=O terminal³⁵ and Cr=O terminal bonds of dehydrated monochromates,³⁷ respectively, indicating the existence of surface tungsten hydrates and the existence of chromium, respectively. ε/γ phase ratio in the products by Raman spectra is consistent with XRD results.

Based on our previous work on WO₃ octahedra⁷ and detailed characterizations of undoped and Cr-doped WO₃ polyhedra, we summarized the morphology evolution and the corresponding crystal growth habits in Figure 4.

As shown in Figure 4a, d, and g, WO_3 products without dopants showed octahedral shapes with {111} exposed facets due to fast growth rate along [001], [010], and [100] directions. The well-defined uniform octahedral structure shows a highly symmetric and regular shape containing 8 facets, 6 vertices, and 12 edges, which exhibits sharp edges and corners as well as smooth surfaces. All of the products with different sizes (nano-/submicro-/microscale) show the same octahedral morphology based on the SEM and TEM images in different magnifications.

It can be seen in Figure 4b, e, and h that lattices of 0.38 nm (insets of Figure 4h) were indexed as [001] and [010] directions of γ -WO₃, which confirms that the equatorial plane perpendicular to the zone axis was (100). Therefore, the introduction of low concentration of Cr dopants to the lattice of WO₃ led to the formation of truncated octahedra with {111}, (001), (010), and (100) exposed facets by significantly reducing the growth rates along [001], [010], and [100] directions. SEM and TEM images in different magnifications show that the sizes of truncated octahedral Cr-WO₃ have a range from tens of nanometres to a few microns.

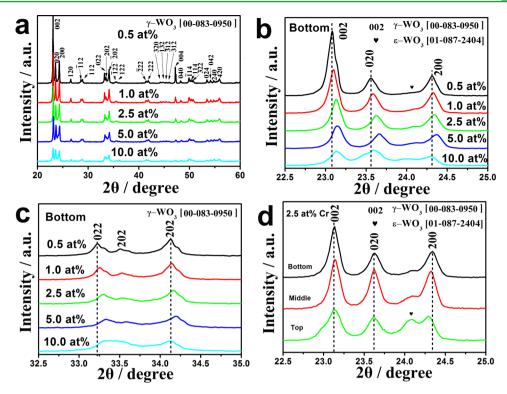


Figure 2. XRD patterns of (a-c) WO₃ products (bottom) doped with different atomic percentage of Cr and (d) WO₃ products collected at different parts of the reactor.

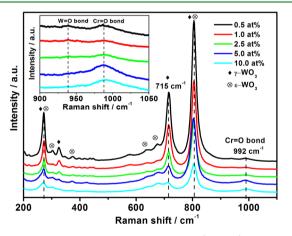


Figure 3. Raman spectra of WO_3 products (bottom) doped with different atomic percentage of Cr (the inset is high magnification of Raman patterns from 900 to 1050 cm⁻¹).

Further introduction of Cr dopants (up to 10.0 at. %) sharply reduced the growth rates along [001], [010], and [100] directions to the slowest one and formed cuboids with (001), (010), and (100) exposed facets (Figure 4c, f, and i, range from a few nanometers to hundreds of nanometers).

3.1.2.2. Effect of Thermodynamic Factors on Size Distributions (Cr Dopants). The size distribution and the size evolution of Cr-WO₃ polyhedra were also studied. The sizes of all of the samples are mainly less than 1.0 μ m as shown in Figure 5a. The increasing percentage of nanometer-size part and decreasing percentage of micrometer-size part indicate that the introduction of Cr dopants prevents the further growth of the crystals. As a result, the median particle diameter (D50) and the mean size of Cr-WO₃ polyhedra decrease with increasing the amounts of Cr dopants (Figure Sb). The median particle

diameter (D50) and mean size of 2.5 at. % Cr-doped WO₃ truncated octahedral were measured to be 0.23 and 0.69 μ m, respectively. The BET surface areas were estimated to be 4.88 (0 at. %),⁷ 5.71 (0.5 at. %), 6.28 (1.0 at. %), 6.76 (2.5 at. %), 7.26 (5.0 at. %), and 8.08 m² g⁻¹ (10 at. %), respectively (blue, Figure 6b). The mean size of Cr-WO₃ polyhedra calculated from BET surface areas decreases from 0.15 to 0.10 μ m (green, Figure 6b, for details, see Supporting Information). The difference in mean sizes obtained by the two methods can be explained by the agglomeration of the particles as well as their motion in aqueous solution that contributed to larger particle size results by the laser-diffraction particle size analyzer.

3.1.3. Detailed Characterization of 2.5 at. % Cr-Doped WO₃ Truncated Octahedra. EDS mapping images of 2.5 at. % Cr-doped WO₃ truncated octahedra in Figure 6a indicate that Cr dopants are uniformly distributed in the particle, and its atomic percentage was calculated to be 1.73%. The surface/ near-surface chemical composition of 2.5 at. % Cr-doped WO₃ was examined by X-ray photoelectron spectroscopy (XPS). The full-range XPS spectrum (Figure 6b) reveals that it is mainly composed of W, Cr, O, and C elements, of which C can be mainly attributed to external contaminations during products collection (including adsorption contaminations on the nanoparticles surface due to exposure to ambient air³⁸). More detailed information on the chemical state of these elements can be obtained from the high-resolution XPS spectra of the W 4f, Cr 2p, and O 1s in Figure 6c-e. The peaks of W $4f_{7/2}$ at 35.7 eV can be assigned to the existence of the WO₃ chemical state at the surface.^{38,39} The binding energies for metallic tungsten, WO₂, and WO₃ were reported to be 31.3, 32.7, and 35.7-36.1 eV, respectively.⁴⁰ Various chromium oxides can be distinguished from each other by XPS. The binding energy (BE) of Cr $2p_{3/2}$ is 577.1 eV, the Cr $2p_{3/2}$ -Cr $2p_{1/2}$ BE separation is 9.8 eV, and O 1s is 530.3 eV. Since both of them

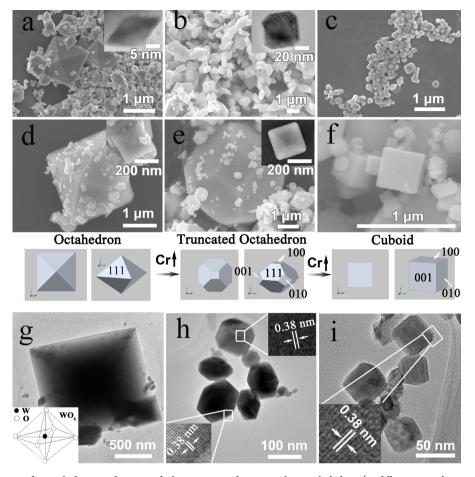


Figure 4. Summarization of morphology evolution and the corresponding crystal growth habits (middle part is the corresponding schematic illustration): SEM images (insets of a and b are the corresponding HRTEM images of nanoparticles, insets of d and e are the corresponding high-manification SEM images of submicroparticles) of $(a, d) WO_3$, (b, e) 2.5 at. % Cr-WO₃ and (c, f) 10.0 at. % Cr-WO₃; TEM images (insets of h and i are the corresponding HRTEM is a schematic diagram of WO₆ octahedron), (h) 2.5 at. % Cr-WO₃, and (i) 10.0 at. % Cr-WO₃, and (i) 10.0 at. % Cr-WO₃.

are consistent with Cr_2O_3 ,⁴¹⁻⁴³ the oxidation state of the dopant can be assigned to Cr^{3+} . Calculated from the quantified peak area, the atomic ratio of Cr/W is estimated to be about 2.83 at. % (XPS), which is a little higher than that estimated by EDS (1.73 at. %). It is consistent with the discussion mentioned above that the majority of the Cr atoms exist in the form of Cr=O terminal bond and thus a chromate layer formed on the crystal surface of WO₃ polyhedron.

3.1.4. Possible Growth Mechanism. The structure of the stable monoclinic WO₃ is ReO₃-type (corner sharing arrangement of WO₆ octahedra). Similarly, γ -WO₃ is also formed by corner sharing of WO₆ octahedra. WO₆ octahedron can be described as follows (the inset of Figure 4g): W ions occupy the corners of a primitive unit cell, O ions bisect the unit cell edges, and each W ion is surrounded by six equidistant oxygen ions. The main differences between different phases are the positions of the W ions within the octahedron and lengths of W–O bonds.

Surface energies and formation energies were calculated for the typical {001} (represent {001}, {010}, and {100}) and {111} surface of γ -WO₃ (Figure 7 and Table 3, detailed calculations and checks on the oxidation state of Cr and W can be found in Supporting Information section S1 and S2, respectively). Indicated by the surface energies and formation energies (ΔE_{form}) listed in Table 3, the ($\sqrt{2} \times \sqrt{2}$)R45 reconstruction of $\{001\}$ was the most stable surface for γ -WO₃, which agreed well with reported simulations^{44,45} and experiments that vapor phase methods usually obtain γ -WO₃ 1D nanostructures on substrates showing [001] growth direction along the length.⁴⁶⁻⁴⁹ However, unlike heterogeneous growth of WO₃ 1D nanostructures on substrates, homogeneous free growth in DC²⁰/RF⁷ thermal plasma CVD showed unique crystal growth habit (thermodynamic property) and 0D octahedra (equilibrium forms) can be obtained. To exclude the influences of elements and groups from raw materials on the surfaces of WO₃, pure W powders were used as raw materials (10–15 μ m, Beijing Xing Rong Yuan Technology Co., Ltd., China) and similar results were obtained (Figure S1, Supporting Information). The well understanding of unique thermodynamic properties of MOX in thermal plasma still needs further simulation and experimental studies on a series of MOX particles synthesized by RF thermal plasma (e.g., ZnO, SnO₂, NiO, TiO₂, etc.).

Similarly, under Cr-doped condition, the form energy $(\Delta E_{\rm form})$ of {111} surfaces indicated easier formation of {111} than {001} surface, which is inconsistent with our experimental results.

Therefore, for γ -WO₃ and Cr-doped γ -WO₃ particles synthesized by RF thermal plasma, the growth mechanism cannot be simply explained by surface energies calculated via **ACS Applied Materials & Interfaces**

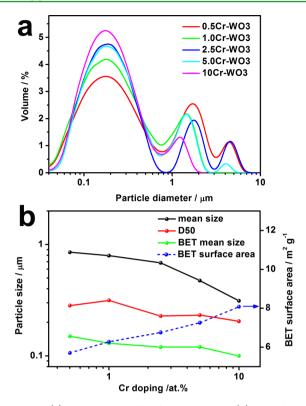


Figure 5. (a) Particle size distribution curves, (b) particle size comparison (black: mean size, red: D50, green: BET mean size), and BET surface areas comparison.

simulations. Despite this, we can set crystal growth habits of pure WO_3 as an initial condition and then reconsider the role of Cr dopants on the morphology evolution.

In the beginning, WO_3 octahedra with {111} exposed facets formed due to fast growth rate along [001], [010], and [100]

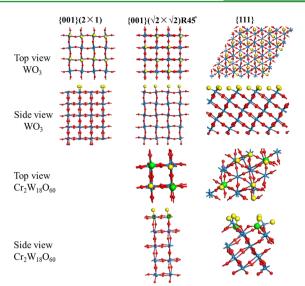


Figure 7. Relaxed surface structures for $\{001\}$ and $\{111\}$ surfaces of γ -WO₃ and Cr-doped γ -WO₃ (where the surface oxygens are colored yellow, bulk oxygens red, W ions blue, and Cr ions green).

Table 3. Relaxed Surface Energies for the $\{001\}$ and $\{111\}$ Surfaces of γ -Monoclinic WO₃

surface	surface energy/ $J \cdot m^{-2}$	$\Delta E_{ m form}$ (adsorption $O_2)/ m eV$	$\Delta E_{ m form} \left(\begin{array}{c} { m doped} \\ { m Cr} ight) / { m eV}$
$\{001\}(2 \times 1)$	1.55	_	_
$\{001\}(\sqrt{2} \times \sqrt{2})$ R45	1.49	-0.23	-1.39
{111}	1.72	-0.20	-2.18

directions. The presence of Cr will cause distortion into the WO₃ matrix, repelling tungsten atoms from centric positions in WO₆ octahedra.^{19,34,50} In addition, since the majority of the Cr

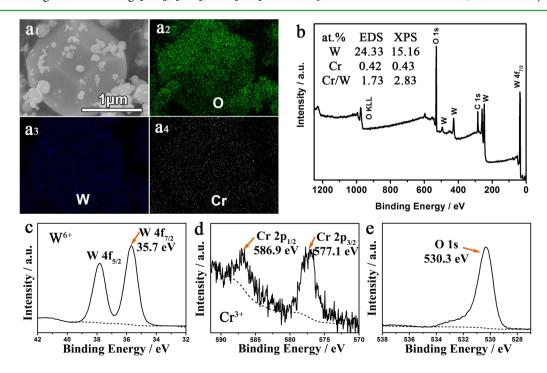


Figure 6. (a) EDS mapping images (O green, W blue, Cr white), (b) XPS spectrum, and (c-e) high-resolution XPS spectra of 2.5 at. % Cr-WO₃ at binding energies corresponding to W 4f, Cr 2p, and O 1s, respectively.

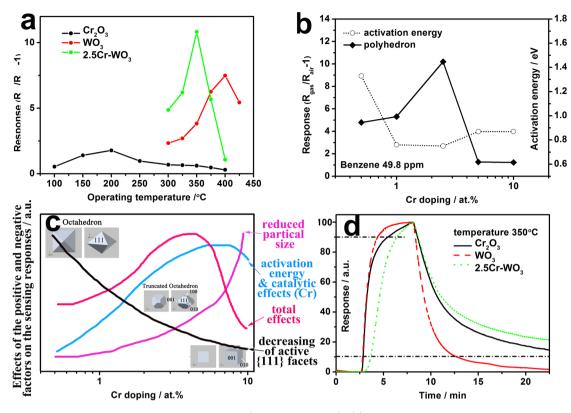


Figure 8. Gas sensing properties of Cr-doped WO₃ polyhedra (49.8 ppm benzene): (a) temperature-dependent responses comparison of Cr_2O_3 nanoparticles, WO₃ octahedra, and 2.5 at. % Cr-WO₃ polyhedra; (b) responses (solid line) and activation energies (dash line) comparison of WO₃ products (collector) doped with different atomic percentage of Cr; (c) the schematic illustration of effects of the positive and negative factors on the gas sensing responses; (d) response–recovery curves comparison of Cr_2O_3 nanoparticles, WO₃ octahedra, and 2.5 at. % Cr-WO₃ polyhedra.

atoms exist in the form of the Cr=O terminal bond according to Raman spectroscopy (Figure 3, also confirmed by EDS and XPS results in Figure 6), Cr atoms favor attachment on the particle surface to form chromates, which might form a chromate layer on the surface of WO₃ polyhedron³⁴ and thus might change the surface energies of different crystal facets similar to selective adsorption of capping or stabilizing agents used in liquid phase method.

Set crystal growth habits of pure WO₃ as an initial condition, the fundamental reason was attributed to coeffects of distortions introduced by Cr into the WO₃ matrix and a chromate layer on the crystal surface, which strongly affected the crystal growth by reducing the growth rates along [001], [010], and [100] directions. Cr dopant-controlled morphology evolution of γ -WO₃ from octahedron to cuboid has been evidenced by XRD patterns, SEM, TEM, and HRTEM images.

3.2. Sensing Properties. As we have mentioned in our previous work, gas sensing processes can be divided into three units, which are gas diffusion/molecule capture (utility factor and some case of receptor function), surface reaction (receptor function), and electron transport (transducer function).^{29,51,52} Unit enhancements can significantly improve the sensing properties of the gas sensors.^{7,29,31} For Cr-doped WO₃ polyhedra, exposed crystal facets, Cr doping, and particle size are key factors for sensing properties due to their effects on the surface reaction and electron transport units.

The crystallographic stacking of (111) planes of γ -WO₃ can be roughly taken as alternating stacking of W and O atoms,¹⁹ which leaves dangling bonds of W⁻ or O⁻ on the surface (highly active crystal surface). It is the main reason why WO₃ octahedra bound by {111} facets showed good gas sensing properties.⁷ Cr dopants brought two advantages on the sensing properties.

On one hand, the introduction of Cr dopants might contribute to the optimal temperature. We prepared Cr_2O_3 nanoparticles by decomposition of ammonium chromate in the same RF thermal plasma. Since the optimal operating temperature of Cr_2O_3 for benzene was 200 °C, the reduced optimal operating temperature of Cr-doped WO₃ from 400 to 350 °C can be attributed to coeffects of Cr^{3+} and W^{6+} when the benzene gas sensing reaction was conducted on the crystal surface (Figure 8a).

On the other hand, sensing responses were improved by proper doping of Cr. The doping of lower valence Cr^{3+} at the site of W^{6+} results in significant decrease of electron concentration or increase the sensor resistance (Supporting Information Figure S2, at least an order of magnitude). Since resistance (electron concentration) varies with operating temperature, its effect on sensing response is complicated.

Therefore, activation energy of semiconductor is employed to clarify the relationship between resistance (electron concentration) and response. At constant surface coverage or constant density of states, the activation energy of semiconductor can be calculated by the Arrhenius plot of the resistance⁵³⁻⁵⁶

$$\frac{1}{\sigma} = \frac{1}{\sigma_0} \exp\left(\frac{\Delta E}{kT}\right) \tag{1}$$

$$\ln \frac{1}{\sigma} = \ln \frac{1}{\sigma_0} + \frac{\Delta E}{kT}$$
(2)

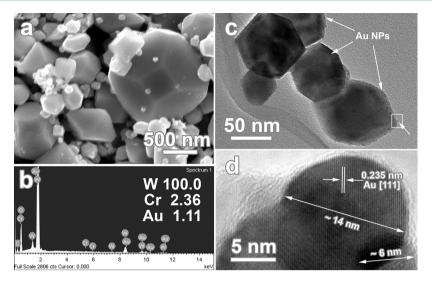


Figure 9. (a) SEM, (b) EDS, (c) TEM, and (d) HRTEM images of Au-decorated 2.5 at. % Cr-doped WO₃ truncated octahedra.

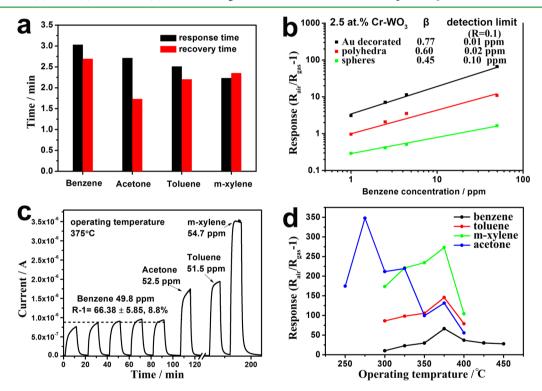


Figure 10. Gas sensing properties of Au-decorated 2.5 at. % Cr-WO₃ polyhedra: (a) response and recovery time; (b) log–log plots comparison of different 2.5 at. % Cr-WO₃ samples; (c) response–recovery curves, repeatability, and (d) responses to different kinds of VOCs at different operating temperature of Au-decorated 2.5 at. % Cr-WO₃ polyhedra.

where σ denotes the conductance, k is the Boltzmann's constant, T is the absolute temperature, and ΔE is the activation energy. Plotting $\ln(1/\sigma)$ against 1/T, ΔE can be obtained.

Sensing results in Figure 8b and c indicate that particle size, activation energy, and catalytic effects of Cr play major roles in improving the sensing responses when low percentage of Cr dopants was introduced, while crystal facets, activation energy, and catalytic effects of Cr reduce the sensing responses when high percentage of Cr dopants was introduced.

For the sample with low percentage of Cr dopants, the response to 49.8 ppm benzene gas increases with increasing Cr dopants due to stronger effect of reduced activation energy

(caused by Cr dopants, dashed line of Figure 8b), particle size (Figure 5), and more edges of the crystal than decreasing percentage of highly active {111} facets (Figure 4). Moreover, it is reported that Cr can have a catalytic effect on the dissociation of BTX compounds into more active species of gases, and its enhancement for BTX sensing was confirmed.^{57–59} Thus, chemical sensitization of Cr component on the surface contributed to the enhanced gas response to benzene in this work. In this case, activities of crystal facets had little effect on sensing responses.

When the effects of the positive and negative factors on the sensing responses were equal to each other, the highest response can be observed (2.5 at. % in this work), which was

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higher than that of pure WO₃ at its optimal operating temperature (400 $^{\circ}$ C).

Further increase of Cr dopants would result in sharp decrease of responses, which can be attributed to dominant effect of negative factors such as less active crystal facets (including less edges of the crystal, and nearly disappearing of highly active {111} facets, Figure 4 and 6), less active species formed by oxidation of the analytic gas before gas sensing reaction (caused by overdoping of Cr on the surface),⁵⁹ and higher activation energy (caused by overdoping of Cr, dashed line of Figure 8b). In this case, particle size had little effects on sensing responses.

Besides, one drawback of Cr-doped WO₃ that should be noted is the response time. Figure 8d shows that the response and recovery time of 2.5 at. % Cr-WO₃ polyhedra at 350 °C (3.72 and >15.0 min, respectively) are worse than those of Cr₂O₃ and WO₃ octahedra, which are also longer than our previous work on other metal oxide sensing materials (2.0–3.3 and <13 min at 350 °C for the same system, respectively).^{7,29,31,53} It means that Cr will reduce the adsorption, reaction rate, and desorption of benzene gas on WO₃ surface (poor response and recovery time), although it can improve the efficiency (high sensing responses) and reduce the operating temperature.

To improve the adsorption, reaction rate, and desorption on the crystal surface, 2.5 at. % $Cr-WO_3$ polyhedra with the highest responses was chosen as the sample for Au decoration (Au loading, 1.11 at. %, Figure 9a and b).

High-magnification TEM images show that ultrasmall Au nanoparticles have been successfully decorated on the surfaces of 2.5 at. % Cr-WO₃ polyhedra (Figure 9c). The corresponding HRTEM image in Figure 9d shows two typical Au nanoparticles with a size of ~ 6 and ~ 14 nm, respectively. The spacing of 0.235 nm is consistent with the value for (111) plane of Au (space group: $Fm\overline{3}m$). The role of noble metals on MOX semiconductors was studied well in the past decade, and their enhancements on the surface reaction were mainly attributed to modify the sensing surface by enhancing the surface reaction due to their catalytic effects (high reaction rates and responses) and the additional depletion layers (high resistances). $^{60-63}$ As a result, the response and recovery time to VOCs were significantly improved to 2.2-3.0 and 1.7-2.7 min, respectively (Figure 10a, 350 °C), and the responses and detection limit were also promoted (Figure 10b, 350 °C).

According to the conductance model limited by the electron transport across the intergranular Schottky barrier,^{64,65} the response equation of grain-based gas sensors,^{60,64,66,67} we can obtained the following equation (for resistance decrease)²⁹

$$\log(R_{\rm air}/R_{\rm gas} - 1) = \log A_{\rm g} + \beta \log p_{\rm g}$$
(3)

A β value of 0.5 is generally indicative of a fully regular microstructure of the nanograins.⁶¹ Disordered microstructure is expected to increase β above this value, whereas local agglomeration or zones of the structure cause a reduction of β below this value.^{66,68} The β values of both Cr-WO₃ polyhedra (0.60) and Au-decorated Cr-WO₃ polyhedra (0.77) were deduced significantly higher than 0.5 (Figure 10b), which might be due to the broad size distribution and nonspherical shape. The β value of Cr-WO₃ spheres (0.45) was lower than 0.5, which might due to local agglomeration or zones of the film.

The enhanced surface reaction and electron transport units allow the sensitive and fast detection of VOCs with remarkable signal-to-noise ratio (Figure 10c). The responses to ppm-level benzene are remarkable and stable ($R_{49.8 \text{ ppm}} = 66.38 \pm 8.8\%$). The sensor has a selective response to acetone at low temperature (275 °C), while it is more sensitive to BTX (benzene, toluene, *m*-xylene) at high temperature (375 °C, Figure 10d).

4. CONCLUSIONS

In summary, the synthesis of Cr-doped WO₃ polyhedra has been demonstrated. Kinetic factors showed little effects on the equilibrium morphology of Cr-doped WO₃ polyhedra, while equilibrium morphologies of WO₃ polyhedra can be controlled by thermodynamic factor (Cr doping). Set crystal growth habits of pure WO₃ as an initial condition, coeffects of distortions introduced by Cr into the WO₃ matrix, and a chromate layer on the crystal surface could reduce the growth rates along [001], [010], and [100] directions. As a result, the morphology evolution was turning out as the following order with increasing Cr dopants: octahedron-truncated octahedron-cuboid. 2.5 at. % Cr-doped WO₃ polyhedra exhibited the highest sensing response due to coeffects of exposed crystal facets, activation energy, catalytic effects of Cr and particle size on the surface reaction, and electron transport units. Au decoration can significantly improve the sensing responses, detection limit, and response-recovery properties of 2.5 at. % Cr-doped WO₃ polyhedra. This study provides an opportunity to synthesize polyhedra with specific exposed facets by tailoring crystal growth habits in RF thermal plasma. The interesting synthetic method may be used for a wide range of MOX synthesized by CVD.

ASSOCIATED CONTENT

S Supporting Information

Mean size calculated from the BET surface area, detailed calculations of surface energies and formation energies, checks on the oxidation state of Cr and W, γ -WO₃ octahedra synthesized by pure W powders, and resistances comparison of WO₃ products (collector) doped with different atomic percentage of Cr. This material is available free of charge via the Internet at http://pubs.acs.org.

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Notes

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